

<b>Notice of References Cited</b>	Application/Control No. 10/584,409		Applicant(s)/Patent Under Reexamination YOON ET AL.	
	Examiner MARTIN ANGEBRANNDT		Art Unit 1722	Page 1 of 1

#### U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-5,298,366	03-1994	Iwasaki et al.	430/321
*	B	US-5,728,509	03-1998	Eda et al.	430/321
*	C	US-5,581,379 A	12-1996	Aoyama et al.	349/5
*	D	US-7,989,154 B2	08-2011	Jeon et al.	430/322
*	E	US-2003/0209819 A1	11-2003	Brown et al.	264/2.5
*	F	US-2008/0248264 A1	10-2008	Jeon et al.	428/195.1
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

#### FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	02-006123	01-1990	Japan	Iguchi	***
	O	01-124294	05-1989	Japan	Kanda et al.	***
	P					
	Q					
	R					
	S					
	I					

#### NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Chang et al., "Shape controlled, high fill factor microlens arrays fabricated by a 3d diffuser lithography and plastic replication method", Opt. Exp. Vol. 12(25) pp 6366-6371 (12/2004)
	V	machine translation of JP 2000-241607, 12 pages (2000)
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.